

**Search Notes**

Application/Control No.

10/728,855

Examiner

Stephen W. Smoot

Applicant(s)/Patent under  
Reexamination

PARK ET AL.

Art Unit

2813

**SEARCHED**

Class	Subclass	Date	Examiner
438	240	6/16/2005	SWS
438	253	6/16/2005	SWS
438	396	6/16/2005	SWS
438	685	6/16/2005	SWS
438	686	6/16/2005	SWS
438	785	6/16/2005	SWS

*S.W.S.***INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Considered all citations from parent application.	6/10/2005	<i>S.W.S.</i> SWS
Key Words: Capacitor, Memory, DRAM; Electrode - Lower, First, Bottom;	6/16/2005	<i>S.W.S.</i> SWS
Tantalum Pentoxide; Titanium Dioxide; Atomic Layer Deposition, Epitaxy - ALD, ALE.	6/16/2005	<i>S.W.S.</i> SWS
Search Tools - EAST (attached): USPAT; US PG PUBS; Derwent; EPO; JPO; IBM TDB	6/16/2005	<i>S.W.S.</i> SWS